PATENT APPLICATION Docket No.: N.C. 79,834

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of: Pique et al.

Serial No.: 09/619,442 Filed: 07/19/2000

For: DIRECT-WRITE LASER TRANSFER AND PROCESSING

Examiner: Fuller, Eric B. Art Group Unit: 1762

Assistant Commissioner of Patents Washington, D.C. 20231

March 4, 2003

AMENDMENT

Sir:

This communication is responsive to the office action of 12/05/2002, setting a three month shortened statutory period of reply.

Please amend the claims as follows:

(New) The method of claim 15, wherein the first laser removes the source material from the surface of the support by matrix assisted pulsed laser evaporation direct write.

28. (New) The method of claim 26, wherein the pulsed laser beam removes the source material from the surface of the support by matrix assisted pulsed laser evaporation direct write.

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